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I .	closure Statement pplicant	Applicant Peter Silverman				
(Use several sheets if necessary) (37 CFR §1.98(b))		Filing Date September 18, 2003	Group Art Unit			

U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						
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	AD						
	AE						

Foreign Patent Documents or Published Foreign Patent Applications								
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	AH							
	AI							
	AJ						<b></b> -	

Other Documents (include Author, Title, Date, and Place of Publication)					
Examiner	Desig.				
Initial	ID	Document			
	AK	Claude Montcalm, "In situ Characterization of EUV Multiplayer Mirrors Deposited by UHV Magnetron Sputterin", Information Science and Technology, Lawrence Livermore National			
		Laboratory, University of California, Livermore, CA			
E	AL	Rick Tejeda, "EUV Mask Modeling", Computational Mechanics Center, Mechanical Engineering Department, University of Wisconsin-Madison, 03/04/1999			
A.	AM	John E. Bjorkholm, "EUV Lithography-The Successor to Optical Lithography?", Intel Technology Journal Q#'98, pages 1-8			
HL.	AN	Matthieu F. Bal et al., "the Influence of Multilayers on the Optical Performance of Extreme Ultra Violet Projection Systems", Optics Research Group, Delft University of Technology			
12	AO	A. Mikkelson et al., "Mounting Effects on Image Placement Errors", Computational Mechanics Center, Mechanical Engineering Department, University of Wisconsin-Madison			
1	AP	S. Wolf et al., "Silicon Processing for the VLSI Era", Volume 1; Process Technology, Second Edition, Lattice Press, Sunset Beach, CA, pages 444-450, 468-483, 777, 649-650, and 666			

Examiner Signature	Date Considered /
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